

EPONA

TECHNOLOGIES



The Epona Story

- **The beginning**
- **The middle**
- **The wait**
- **The now**



**DRAM®- Device for Remediation and
Attenuation of Multiple pollutants**



DRAM - The sustainable environmental solution



“the science in a single slide”



- A by-product of whisky production can be deployed to remediate contaminated water
- The process is achieved by a combined biological, chemical and physical interaction
- Effective for groundwater and wastewater



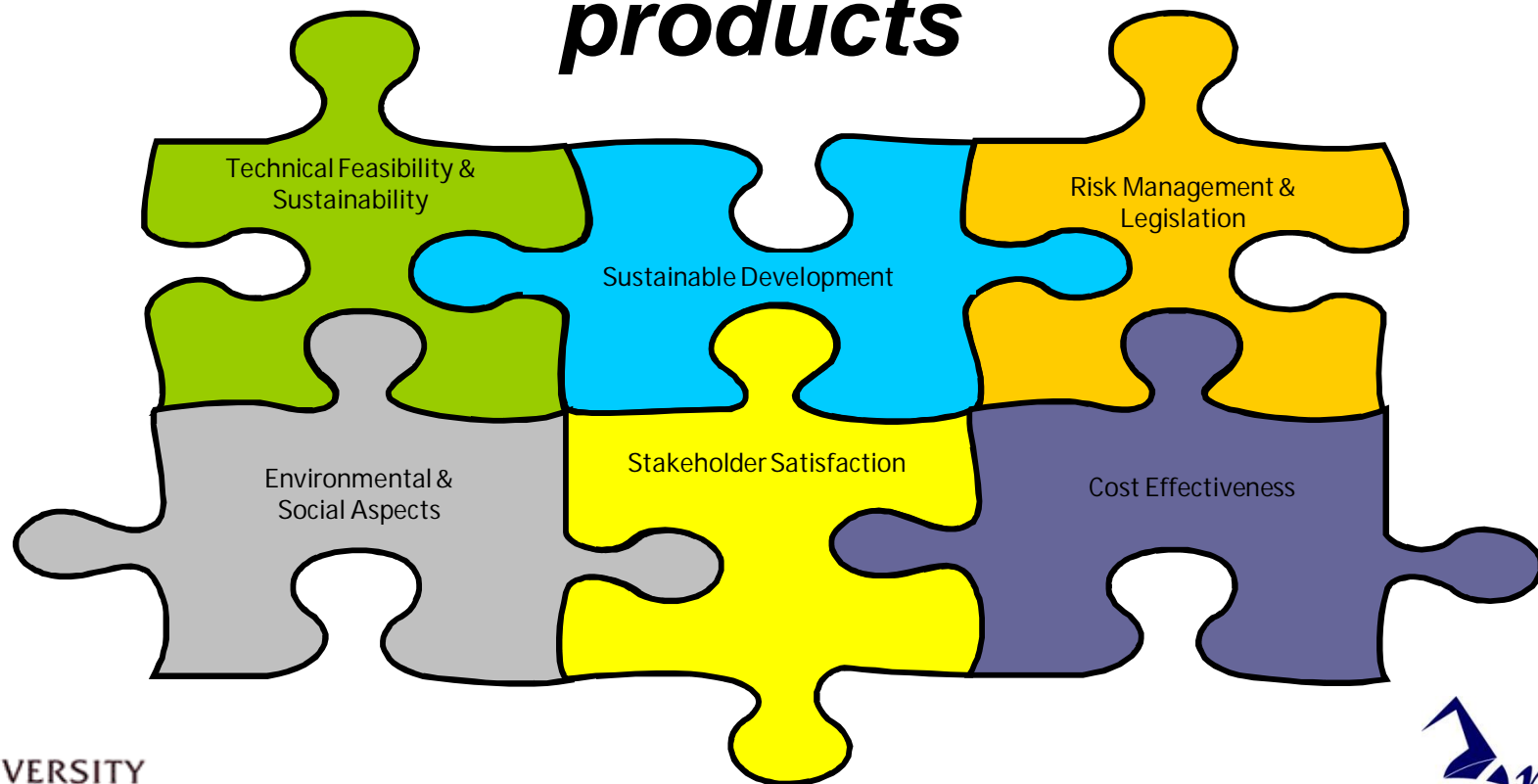


Audit of Science

- Significant screening of over 40 chemicals
- Transfer from laboratory to full scale
- Six field trials conducted and testimonials
- Storage trials of DRAM® and detailed analysis
- Extensive deployment testing
- Independent verification
- Linkage to users for dissemination
- First contracts completed



Science- Just the First Step in the commercialisation of Environmental products





The Product and Benefits

- Sustainable and cost-effective remediation of wastewater and groundwater
- A bespoke service by understanding client's problem and developing a solution
- Development of a service-led product company



Value Addition: Application to Wastewater



- The product will be readily assembled and flexible to applications
- Applicable as a primary or polishing step
- Cost will be the key driver
- Minimal carbon footprint
- Software completed to support application



The Product and Benefits

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The Wait.....



Customers





The Now.....

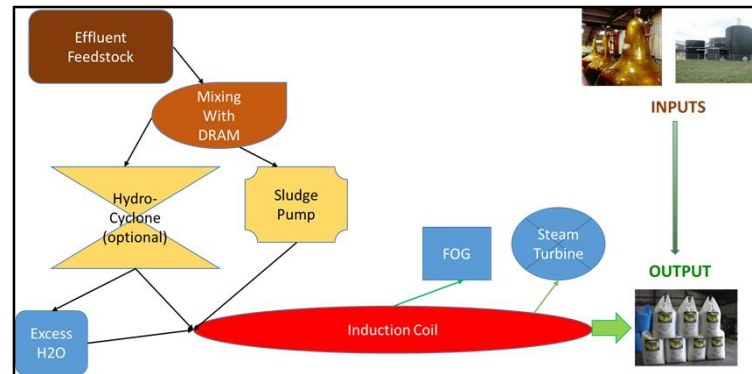
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Team

- COO, Leigh Cassidy has committed to company full time
- CTO, Graeme Paton retains UoA post but committed to company
- External Chairman p/t but committed to company
- Sales Staff
- Collaboration
- JV
- Distribution Agreements

Current Projects





Device for Remediation and Attenuation of Multiple Pollutants

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